

Thursday 24 May

09:00

Session 4: Innovative processing methods Session 09:00-09:20 Innovative Processing of SRF materials Speaker Claire Antoine 09:20-09:50 Treatment of SRF 1-cell test cavities for evaluation of the effect of Gas Cluster Ion Beams on high power cavity Q Speaker D. R. Swenson 09:50-10:15 Plasma Etching of Niobium Surfaces Speaker M. Rašković 10:15-10:25 **break** 10:25-10:45 ECR plasma: a possible in-situ cavity processing technique Speaker Genfa Wu 10:45-11:10 Novel Surface Treatments for RRR Niobium Speaker Roy Crooks 11:10-11:35 Advanced Nb oxide surface modification by cluster ion beams Speaker Zeke Insepov 11:35-12:00 Chemical Mechanical Polishing for Manufacturing of Smooth Nb Surfaces Speaker Sinan Muftu 12:00